L Number	Hits	Search Text	DB	Time stamp
1	11127	((Chemical adj mechanical adj polish\$3) or CMP or planariz\$5) and (slurry or composition)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/08/07 13:02
9	41	(((Chemical adj mechanical adj polish\$3) or CMP or planariz\$5) and (slurry or composition)) and (citric same citrate)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/08/07 13:03